



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

MARK I. GARDNER  
MARK C. GILMER

Serial No.: 09/079,759

Filed: May 15, 1998

For: METHOD OF MAKING AN  
ADVANCED ISOLATION  
STRUCTURE FOR HIGH DENSITY  
SEMICONDUCTOR DEVICES  
(as amended)

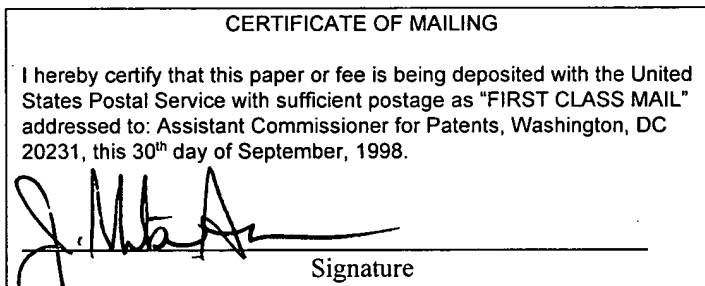
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§ Examiner: W. Mintel  
§  
§ Group Art Unit: 2811  
§  
§ Att'y Docket: 2000.002600/TT2587  
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**RESPONSE TO RESTRICTION  
REQUIREMENT DATED AUGUST 6, 1998**

Assistant Commissioner for Patents  
Washington, D.C. 20231

Sir:



This paper is submitted in response to the Restriction Requirement dated August 6, 1998 for which the date for response was September 6, 1998.

In response to the restriction requirement which the Examiner imposed, Applicants elect, without traverse, to prosecute claims 20-28, *i.e.*, the Group II claims.

Additionally, please amend the title of the above-referenced application to read as follows:

-- METHOD OF MAKING AN ADVANCED ISOLATION  
STRUCTURE FOR HIGH DENSITY SEMICONDUCTOR DEVICES --.

SAU 2811 #


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3pta  
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A request for a one month extension of time to respond is included herewith along with the required fee. This one month extension will bring the due date to October 6, 1998, which is within the six-month statutory period.

The Examiner is invited to contact the undersigned attorney at (713) 934-4055 with any questions, comments or suggestions relating to the referenced patent application.

Respectfully submitted,

Date: September 30, 1998



J. Mike Amerson  
Reg. No. 35,426  
WILLIAMS, MORGAN & AMERSON, P.C.  
7676 Hillmont, Suite 250  
Houston, Texas 77040  
(713) 934-7000  
(713) 934-7011 (facsimile)

ATTORNEY FOR APPLICANTS